

**Method and device for treating semiconductor bars with
a liquid or a gas**

Abstract

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In a method of treating semiconductor bars with a liquid or a gas, at least one semiconductor bar is transported by means of at least two revolving continuous means which are arranged in parallel and are spaced apart from one other at right angles to a transport direction and which have portions of the semiconductor bar supported thereon
10 which are spaced apart from one another in the longitudinal direction of the semiconductor bar, while the latter is being treated with a liquid or a gas.

Fig. 1